

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	112	((plasma near2 etch\$6) and (wet near2 process\$6)) and ((kojima.in. and masayuki.in.) or hitachi.asn.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/23 14:40
L2	43	l1 and ashing	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/23 14:43
L3	33	l1 and (etch\$6 with (al or refractory))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/23 14:42
L4	64	l1 and (etch\$6 with (al or aluminum or aluminium or refractory))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/23 14:42
L5	27	l4 and ashing	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/23 14:43